

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	: Shimbori, H.
Appl. No.	: 10/561,760
Filed	: December 21, 2005
For	: RESIN FOR POSITIVE RESIST COMPOSITION, AND POSITIVE RESIST COMPOSITION USING THE SAME, LAMINATE AND METHOD FOR FORMING RESIST PATTERN
Examiner	: Lee, Sin J.
Group Art Unit	: 1752

**AMENDMENT AND RESPONSE TO OFFICE ACTION****Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **September 11, 2007**, please consider the following amendments and remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 10 of this paper.